

(Micro) Rectenna Arrays for Infrared Power Conversion



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Rectenna Arrays for Infrared Power Conversion – Power Beaming in Space







(Micro) Rectenna Arrays for Infrared Power Conversion – Terrestrial Power Beaming



UAS sustainment







Other applications: Battlefield Data Transfer and Identification





- What are microrectennas and microrectenna arrays?
- Materials for microrectenna arrays
- Vertical MIM diode rectifiers
 - J-V curve experiments and modeling
 - Estimation of responsivity and direct current
- Horizontal stripe-teeth metamaterial arrays
 - Design and fabrication
 - Analysis
 - Response to cw lasers





Diode rectification (assumes ideal , highly nonlinear I-V curve)



Dr. W. C. Brown, Raytheon Corporation (1964)



Figure 9. 5.61-GHz circular polarized printed rectenna with over 78% efficiency [38

>75% efficient 5.61 GHz rectenna array (TAMU) – IEEE Microwave Journal (2002)

McSpadden *et. al.*, IEEE Trans. Microw. Theory Tech. v. 46 p.2053 (1998)

η > 80% for 5.8 GHz!





Accurate measurements of infrared/visible frequencies



Radiative power in Watts



Responsivity of Metal-Insulator-Metal (MIM) Diodes



 Tinkham: Responsivity of Superconductor – Insulator – Superconductor/Normal junctions (1982)







What are microrectennas and microrectenna arrays?





Photovoltaic (electron-hole generation with semiconducting bandgap)

PV doesn't absorb photon energies less than bandgap





Perspective view of microrectenna



Simple rectification verification at 1 MHz (NbOx – based diode)





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arrays



- Materials systems investigated:
 - $M/Nb_2O_5/NbO_x/Nb$, M = Ag/Ti, Au/Ti, Pt/Ti, others
 - M/Al₂O₃ (ALD)/Al, M = Al, Au
- Al or Nb ground planes
- Au wire antennas underneath Al electrode
 - Small cluster of nanorectennas
 - Antennas run between electrodes in top plane, vertical MIM diode (same as other cases)



Vertical MIM diode rectifiers (Al- and Nb-based)



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Need accurate knowledge of MIM diode's I-V curve to predict R_Q

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Vertical MIM diode rectifiers

$$R_{\mathbf{Q}} = \frac{e}{\hbar\omega} \left[\frac{I_{dc} \left(V_{0} + \hbar\omega/_{e} \right) - 2I_{dc} \left(V_{0} \right) + I_{dc} \left(V_{0} - \hbar\omega/_{e} \right)}{I_{dc} \left(V_{0} + \hbar\omega/_{e} \right)^{10} - I_{dc} \left(V_{0} - \hbar\omega/_{e} \right)} \right]$$
Must model I-V curve to predict rectification responsivity (A/W), especially at high voltages for R_Q!



NSRDEC MIM diode model





New physics in model

- Exact solution to trapezoidal potential barrier: no WKB approximation
- Principle of "equal action" to solve image force
 problem
- Effective mass not equal to electron rest mass
- Note convention: larger barrier on left

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Conduction and rectification in $\ensuremath{\mathsf{NbO}_{x^{\!-}}}$ and NiO-based metal-insulator-metal diodes

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Barrier heights in format: ϕ_{+}/ϕ_{-}

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Eleven orders of magnitude in current through NbOx – based diodes



 $\cdot m_2 = 0.16 m_0$





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Stripe arrays exhibit cross-

stripe resonances









X



Stripe-teeth resonances (AI-AI₂O₃-Al microrectenna arrays)



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Stripe-teeth resonances (AI-Al₂O₃-Al microrectenna arrays)



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Stripe-teeth resonances (Al-Al₂O₃-Al microrectenna arrays)



 Good (not perfect) agreement between FTIR-measured spectra and simulated reflectivity. Insensitive to angle-of-incidence (to > 33°).

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- Designed for maximum asymmetry/non-linearity consistent with stripes to extract current
- AI-AI₂O₃-AI arrays have excellent quality and controlled resonances
 - Make broadband with chirped arrays
 - With "Au wire" responds to cw visible lasers
- Au/Ti-Nb₂O₅-NbO_x-Nb has a lossier ground plane (Nb) and, while an excellent electronic-quality oxide, antenna resonances much broader and weaker
 - However there is an interesting response to cw lasers with small dimensions ("nanorectenna array")



Nanorectenna array output power from cw laser illumination!





Nanowire-based nanorectenna clusters





Figure 1. Schematic ray diagram and cross-sectional view of the present lithography system. a) Ray diagram of the basic lens system of image formation, which is composed of two different sets of OL, IL, and PL. The first set magnifies the sample image to the lithography plane with a magnification ranging from 50 to 300 times, while the second set further magnifies this image to the viewing screen. b) The specially designed hardware which was developed based on the modification of a 200 kV TEM equipped with a field emission gun (JEM-2010F, JEOL Ltd.).

- Inverted Au/Al₂O₃ (ALD)/Al stack
- Au wire antennas underneath Al electrode
- Regular, high-resolution arrays of lines and dots
- Unique nanopatterning approach



Electrode #1

Vertical diode, horizontal antennas

Nano Fabrication Laboratory

SEOUL NATIONAL UNIVERSITY





Nanowire-based nanorectenna

clusters







Modeling AI-Al₂O₃-Au nanorectennas to explain data

Hypothesis I: steps in I-V curve are due to oscillations in transmission function through barrier layer in MIM diode, which are due to interferences in the transmission through the trapezoidal (image-modified) potential



Hypothesized "step" in I-V curve



A few states below the Fermi level have tunneling transmission resonances across barrier into empty states (producing steps in the I-V curve at low temperatures), but V must be at least > ϕ_+ (for forward bias) and at least > ϕ_- (for reverse bias)



2-10 nm thick barrier layer, K = 6, Temp = 293 K or 1 K Note: V > 0 is *reverse bias*



Hypothesis II: Shift in J-V curve due to laser illumination may be due to field and plasmonic intensification near asperities in barrier layer (aluminum oxide)







Other possibilities for large response to cw visible laser: rectification, charging

Note: V > 0 is *reverse bias*; opposite from previous notation.



New temperature gradient in NSRDEC MIM diode model; regions 1 and 3 are at different temperatures. Barrier heights: ϕ_{-} and ϕ_{+} , where $\phi_{-} > \phi_{+}$.





- Nonlinear rectifying metadevices create new opportunities (quantum and nonlinear plasmonics)
- Nb- and Al-based stripe-teeth metamaterial arrays designed and analyzed
 - Both have cross-stripe resonances
 - Au/NbOx/Nb: broad, weak resonances
 - AI/AI₂O₃/AI: well-controlled absorption spectrum
 - Standing wave resonances dependent on y-pitch
 - Angle of incidence has little effect to at least 33 deg.
 - J-V curves for Ag(Ti)/NbOx/Nb show $\phi_{-}/\phi_{+} = 0.41/0.77$ eV
 - J-V curves for Al/Al₂O₃/Au show ϕ_{-}/ϕ_{+} reduced
 - Curves shift with focused laser due to field enhancement from AIOx roughness, photoemission/charging, and heating effects
 - "Steps" in I-V?
 - Rectification responsivity predicts shift due to laser illumination?
- Large direct current at V = 0 from Ag(Ti)/NbOx/Nb and Al/Al₂O₃/Au microrectenna arrays much larger than predicted by classical and quantum rectification formulas
 - Rectification or photothermoelectric effect?
 - Are steps in MIM diode I-V curves possible?





- A new early applied program on narrowband infrared rectenna arrays starting in FY17.
- Proof-of-concept experiments (labscale demonstrations) will be carried out for power and data beaming.





Potential application: Wireless power/data transfer/communications (Warfighter/Soldier/Squad and/or UAS sustainment)

